UKNC Conference Programme



STRATHCLYDE 2024

University of Strathclyde 10th-11th January 2024

Code of Conduct.

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Harassment includes offensive verbal comments related to gender, gender identity and expression, age, sexual orientation, disability, physical appearance, body size, race, ethnicity, religion, technology choices, sexual images in public spaces, deliberate intimidation, stalking, following, harassing photography or recording, sustained disruption of talks or other events, inappropriate physical contact, and unwelcome sexual attention.

Any participants who have concerns that the Code of Conduct has been breached should contact one of the UKNC committee members responsible for conferences:

Prof David Binks:david.binks@manchester.ac.ukDr Fabien Massabuau:f.massabuau@strath.ac.ukProf Rachel Oliver:rao28@cam.ac.uk

Our sponsors





Wednesday 10th of January 2024.

09:30-10:25 Arrival, Registration and Coffee

- 10:25-10:30 Opening Remarks
- 10:30-11.15 Foxon Lecture Chair: Rob Martin

Porous GaN

Prof Rachel Oliver University of Cambridge, UK

11.15-12.30 Session 1: Characterisation - Chair: Rob Martin

11.15-11.30 Holistic characterization of III/N and III/V nanowires using experimental big data <u>Stephen Church¹</u>, Aswani Vilasam², Nikita Gagrani², Hoe Tan², Chennupati Jagadish², Yunyan Zhang³, Huiyun Liu⁴, Francesco Vitale⁵, Daniel Repp⁵, Carsten Ronning⁵, Nian Jiang⁶, Hannah Joyce⁶ and Patrick Parkinson¹

- ¹ University of Manchester, UK
- ² Australian National University, Canberra, Australia
- ³ Zhejiang University, Hangzhou, China
- ⁴ University College London, UK
- ⁵ Friedrich-Schiller-University of Jena, Jena, Germany
- ⁶ University of Cambridge, UK

11.30-11.45 Effect of indium content on the optical properties of zincblende InGaN/GaN quantum wells

<u>D. Dyer,</u>¹ M. J. Kappers,² D. J. Wallis,^{2,3} R. A. Oliver,² and D. J. Binks¹ ¹Department of Physics and Astronomy & Photon Science Institute, University of Manchester, UK ²Department of Materials Science and Metallurgy, University of Cambridge, UK ³Centre for High Frequency Engineering, Cardiff University, UK

11.45-12.00 Misorientation and Strain Associated with Threading Dislocations in GaN using Electron Backscatter Diffraction

<u>K. P. Hiller</u>¹, A. Winkelmann^{1, 2}, B. Hourahine¹, P. J. Parbrook³, G. Cios², C. Trager-Cowan¹, and J. Bruckbauer¹

¹Advanced Materials Diffraction Lab, Department of Physics, SUPA, University of Strathclyde, UK

²Academic Centre for Materials and Nanotechnology, AGH University of Krakow, Poland

³Tyndall National Institute, University College Cork, Ireland

12.00-12.15 Temperature and excitation dependence of recombination efficiency in cubic InGaN/GaN Quantum Wells <u>W. R. Fieldhouse-Allen¹</u>, M. J. Kappers², M. Frentrup², D. J. Wallis^{2,3}, R. A. Oliver² and D. J. Binks¹

¹Department of Physics and Astronomy, University, of Manchester, UK

²Department of Materials Science & Metallurgy, University of Cambridge, UK ³ Centre for High Frequency Engineering, University of Cardiff, UK

- 12.15-12.30 Deep level defects in dilute Al_xGa_{1-x}N alloy

 <u>L.J. Sun</u>^{1*}, P. Kruszewski², V.P. Markevich¹, A.R. Peaker¹, I.F. Crowe¹, J. Plesiewicz², P. Prystawko², D. Binks³, and M.P. Halsall¹
 ¹Photon Science Institute and Department of Electrical and Electronic Engineering, The University of Manchester, UK
 ²Institute of High-Pressure Physics, Polish Academy of Sciences, Poland
 ³Dept. of Physics and Astronomy & Photon Science Institute, University of Manchester, UK
- 12.30-13.30 Lunch sponsored by Attolight

13.30-14.15 The Humphreys Lecture- Chair: Fabien Massabuau

Development of β -Ga₂O₃ for High Voltage Power Electron Devices Prof Jim Speck University of California Santa Barbara, USA

14.15-15.30 Session 2: Gallium Oxide- Chair: Fabien Massabuau

 14.15-14.30 β-Ga₂O₃ trench Schottky barrier diodes for high voltage applications <u>Vanjari Sai Charan¹</u>, Aditya Bhat Kundapura¹, Indraneel Sanyal¹, Yuke Cao¹, Matthew Smith¹, and Martin Kuball¹ ¹Center for Device Thermography and Reliability, HH Wills Physics Laboratory, University of Bristol, UK

 14.30-14.45 Cathodoluminescence study of dislocations in ELOG α-Ga₂O₃ <u>M. Maruzane</u>¹, Y. Oshima², O. Makydonska¹, P. R. Edwards¹, R.W. Martin¹, and F.C-P Massabuau¹
 ¹ Department of Physics, SUPA, University of Strathclyde, UK
 ² National Institute for Materials Science, Tsukuba, Japan

14.45-15.00 Deep level traps in epi-layers of (010) β-Ga₂O₃ grown by metal organic chemical vapour deposition on Sn-doped β-Ga₂O₃ substrates

 <u>C. A. Dawe¹</u>, V. P. Markevich¹, M. P. Halsall¹, I. D. Hawkins¹, A. R. Peaker¹, D. Binks², A. Nandi³, I. Sanyal³ and M. Kuball³
 ¹ Photon Science Institute and Department of Electrical and Electronic Engineering, The University of Manchester, UK
 ² Photon Science Institute and Department of Physics and Astronomy, The University of Manchester, UK
 ³ Center for Device Thermography and Reliability, University of Bristol, UK

 15.00 -15.15 Comparative study of the optical properties of α-, β-, and κ-Ga₂O₃

- <u>L. Penman</u>,¹ Z. Johnston,¹ Y. Oshima,² C. McAleese,³ P. Mazzolini,^{4,5} M. Bosi,⁵ L. Seravalli,⁵ R. Fornari,^{4,5}, and F. Massabuau¹ ¹ Department of Physics, University of Strathclyde, UK
 - ² National Institute for Materials Science, Japan

 ³ AIXTRON Ltd., Cambridge, UK
 ⁴ Department of Mathematical, Physical and Computer Sciences, University of Parma, Italy
 ⁵ IMEM-CNR, Parma, Italy

- 15.15 -15.30 Heteroepitaxy of β-Ga₂O₃ on 4H-SiC via Metal Organic Chemical Vapor Deposition Indraneel Sanyal, Arpit Nandi, David Cherns, and Martin Kuball Center for Device Thermography and Reliability, University of Bristol, UK
- 15.30-16.00 Coffee sponsored by Zeiss
- 16.00-17.00 Session 3: Growth and Emerging Materials- Chair: David Binks
- 16.00 -16.15 MOCVD overgrowth of μ-honeycomb AlGaN structures
 Sandeep M. Singh^{1, 2*}, Vitaly Zubialevich¹, and Peter J. Parbrook^{1, 2}
 ¹ Tyndall National Institute, University College Cork, Ireland
 ² Electrical and Electronic Engineering, School of Engineering, University College Cork, Ireland
- *16.15 16.30* High-temperature molecular beam epitaxy of hexagonal boron nitride and hBNgraphene lateral heterostructures.

T.S. Cheng¹, J. Bradford¹, T.S.S. James¹, C.J. Mellor¹, K. Watanabe², T. Taniguchi², I. Aharonovich³, L.F. Zagonel⁴, B. Gil⁵, G. Cassabois⁵, P.H. Beton¹, and <u>S.V. Novikov¹</u>
¹School of Physics and Astronomy, University of Nottingham, UK
²National Institute for Materials Science, Japan
³School of Mathematical and Physical Sciences, University of Technology Sydney, Australia
⁴Institute of Physics, University of Campinas, Brazil
⁵Laboratoire Charles Coulomb, CNRS-Université de Montpellier, France

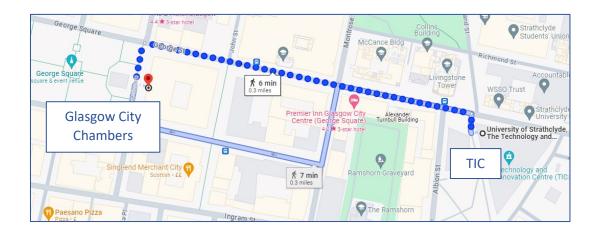
16.30 -16.45 Morphological, structural and strain relaxation properties of porous InGaN-based pseudo-substrate for long wavelength μ-LEDs
 <u>Yihong Ji¹</u>, Martin Frentrup¹, Xiaotian Zhang¹, Jakub Pongrácz^{1,2,3}, Simon M. Fairclough¹, Yingjun Liu⁴, Tongtong Zhu⁴, and Rachel A. Oliver^{1,4}
 ¹University of Cambridge, UK
 ²Czech Academy of Science, Czech Republic
 ³Brno University of Technology, Czech Republic
 ⁴Poro Technologies Ltd, UK

 16.45 -17.00 Inductively-coupled plasma etching of aluminium nitride structures for nextgeneration quantum technology applications

 <u>H. Bilge Yağcı^{1,2}</u> Sam G. Bishop^{1,2}, Joseph K. Cannon^{1,2}, John P. Hadden^{1,2}, Anthony J. Bennett^{1,2}
 ¹School of Engineering, Cardiff University, UK
 ²Translational Research Hub, Cardiff University, UK

17.00 AGM

19.00Drinks Reception & Conference Dinnersponsored by AIXTRONAt City Chambers



Thursday 11th of January 2024.

09.00-09.45 Invited Talk- Chair: Rachel Oliver

Scandium Aluminium Nitride Prof Dr. Oliver Ambacher *Albert-Ludwigs-Universität Freiburg, Germany*

09.45-11.00 Session 4: Electrical Devices- Chair: Rachel Oliver

09.45 -10.00 Nanoscale mapping of threshold voltage distribution in GaN-based high electron mobility transistor structures

<u>C. Chen</u>¹, S. Ghosh¹, P. De Wolf², F. Adams¹, M. J. Kappers¹, D. J. Wallis^{1, 3}, and R. A. Oliver¹

¹ Department of Materials Science and Metallurgy, University of Cambridge, UK

- ² Bruker Nano Surfaces, California, USA
- ³ Centre for High Frequency Engineering, University of Cardiff, UK
- 10.00 -10.15 Electric field distribution in quasi vertical diodes by second harmonic generation Anjali Anjali¹, Yuke Cao¹, James Pomeroy¹, Eldad Bahat Treidel², Enrico Brusaterra², Mihaela Wolf², Oliver Hilt², and Martin Kuball¹
 ¹ Center for Device Thermography and Reliability, H.H. Wills Physics Laboratory,
 - University of Bristol, UK

² Ferdinand-Braun-Institut (FBH), Germany

10.15 -10.30 An ab initio study of electron transport in ultra-wide band gap semiconductors <u>Patrick Williams</u>, Angela Dyson, and Patrick Briddon Newcastle University, UK

10.30 -10.45 A Modelling study of carriers transport in GaN/AlGaN superlattices using Monte Carlo simulation

<u>Mengxun Bai</u> and Judy Rorison Electrical and Electronic Engineering, University of Bristol, Bristol, UK

10.45 -11.00 Temperature-Dependent Dynamic On-Resistance of Normally-Off GaN HEMTs

<u>Francesca Adams</u>¹, Suzanne Lo², Charley Shi², Aaron Wadsworth², Saptarsi Ghosh¹, Matthew G. S. Pearce², David J. Wallis^{1,3}, Duleepa J. Thrimawithana², Rachel A. Oliver¹

¹ Dept of Materials Science and Metallurgy, University of Cambridge, UK
 ² Dept of Electrical, Computer and Software Engineering, University of Auckland, New Zealand

³ Centre for High Frequency Engineering, University of Cardiff, UK

11.00-11.30 Coffee break sponsored by CSA Catapult

11:30-12:15 Session 5: Visible Emitters Chair: Peter Parbrook

11.30 -11.45 Saturation of localisation centres and efficiency droop in InGaN/GaN quantum wells

*R. M. Barrett*¹, *D. Dyer*¹, *J. M. McMahon*², *S. Schulz*², *M. J. Kappers*³, *R. A. Oliver*³, and <u>*D. Binks*¹</u>,*

¹ Dept. of Physics & Astronomy & Photon Science Institute, University of Manchester, UK

² School of Physics & Tyndall National Institute, University College Cork, Ireland
 ³ Department of Materials & Metallurgy, University of Cambridge, UK

11.45 -12.00 Gallium nitride hybrid photonic integration – challenges and applications

<u>Jack A Smith</u>¹, Saptarsi Ghosh², Benoit Guilhabert¹, Rachel A Oliver², and Michael J Strain¹

¹ Institute of Photonics, University of Strathclyde, Technology and Innovation Centre, UK

² Department of Materials Science and Metallurgy, University of Cambridge, UK

12.00 -12.15 High-speed single pixel imaging using a GaN micro-LED array

<u>G. E. Johnstone^{1*}</u>, J. Gray¹, S. Bennett², P. Murray², S. D. Johnson³, M. J. Padgett³, C. F. Higham⁴, R. Murray-Smith⁴, F. Dehkhoda⁵, R. K. Henderson⁵, J. Herrnsdorf¹, M. D. Dawson¹, and M. J. Strain¹

¹ Institute of Photonics, Department of Physics, University of Strathclyde, Technology and Information Centre, UK

- ² Department of Electronic and Electrical Engineering, University of Strathclyde, UK
- ³ School of Physics and Astronomy, University of Glasgow, UK
- ⁴ School of Computing Science, University of Glasgow, UK

⁵ School of Engineering, University of Edinburgh, UK

12:15-12:45 Flash Presentations for posters

2 minutes per poster (maximum 3 slides)

12:45-14:00 Lunch & Poster Session

14:00-15:15 Session 6: UV Emitters - Matthew Halsall

14.00 -14.15 The influence of point defects and threading dislocations on the opto-electronic properties of UV-C LEDs

G. Kusch¹, Viesturs Spūlis¹, M. Schilling², F. Biebler², B. Belde², F. Mehnke², M. Guttmann², S. Hammersley, T. Wernicke², M. Kneissl², and R. A. Oliver¹ ¹ Dept. of Materials Science and Metallurgy, University of Cambridge, UK ² Technische Universität Berlin, Institute of Solid State Physics, Germany

14.15 -14.30 Controlling Point Defects in AlGaN

<u>Douglas Cameron</u>¹, Marcel Schilling², Gunnar Kusch³, Paul R. Edwards¹, Tim Wernicke², Michael Kneissl², Rachel A. Oliver³, and Robert W. Martin¹ ¹ Department of Physics, SUPA, University of Strathclyde, UK ² Institute of Solid-State Physics, Technische Universität Berlin, Germany

³ Department of Materials Science and Metallurgy, University of Cambridge, UK

14.30 -14.45 Ultraviolet-C CMOS-controlled micro-light-emitting diode array

<u>Jonathan J.D. McKendry¹</u> Enyuan Xie¹, Jordan Hill¹, Hichem Zimi¹, Johannes Herrnsdorf¹, Erdan Gu¹, Robert K. Henderson² and Martin D. Dawson¹ ¹ Institute of Photonics, Dept. of Physics, Univ. of Strathclyde, UK ² School of Engineering, Joint Research Institute for Integrated Systems, Institute for Micro and Nano Systems, University of Edinburgh, UK

14.45 -15.00 Effect of Mg doping on polarisation-doped AlxGa1-xN (x < 0.35)

<u>P. Milner^{1,2}</u>, V.Z. Zubialevich¹, S.M. Singh^{1,2}, R. Finn^{1,2}, B. Corbett¹, P.J. Parbrook^{1,2} ¹ Tyndall National Institute, Ireland ² Dept of Electrical and Electronic Engineering, University College Cork, Ireland

15.00 -15.15 Theoretical study of the influence of carrier density screening on Urbach tail energies in (Al,Ga)N quantum well systems

<u>Robert Finn</u>¹, M. O'Donovan², T. Koprucki² and S. Schulz^{1,3}

- ¹ Tyndall National Institute, University College Cork, Ireland
- ² Weierstrass Institute (WIAS), Germany
- ³ School of Physics, University College Cork, Ireland

15:15-15:45 Coffee sponsored by IQE

15.45-16:00 Closing Remarks & Student Prizes

16:00 Depart

Posters (11th Jan 2024 12:45-14:00)

Reducing GaN-on-diamond thermal boundary resistance by nanostructured interface

<u>Xiaoyanq Ji</u>¹, Sai Charan Vanjari¹, Daniel Francis², Felix Ejeckam², Marko Tadjer³, Travis Anderson³, James W. Pomeroy¹, Martin Kuball¹

¹ HH Wills Physics Laboratory, University of Bristol, UK

² Akash Systems, San Francisco, USA

³ Naval Research Laboratory, Washington DC, USA

Constant photocurrent method to probe the sub-bandgap absorption in wide bandgap semiconductor films: the case of α -Ga₂O₃

<u>D. Nicol¹</u>, S. Reynolds², J. Roberts³, J. Jarman⁴ P. Chalker³, and F. Massabuau¹

¹ University of Strathclyde, Glasgow, UK

² University of Dundee, Dundee, UK

³University of Liverpool, Liverpool, UK

⁴University of Cambridge, Cambridge, UK

Sample size effects on chronoamperometry during electrochemical etching of porous GaN

<u>Ben Thornley</u>, Galih R. Suwito, Jiawei Zhang, Menno Kappers, and Rachel Oliver ¹Department of Materials Science and Metallurgy, University of Cambridge, UK

Hybrid device fabrication using Mesoporous GaN Distributed Bragg Reflectors grown on Silicon

<u>B. Guilhabert¹</u>, S. Ghosh², M. Toons¹, D. Jevtics¹, M. Kappers², R.A. Oliver² and M.J. Strain¹

¹ Institute of Photonics, University of Strathclyde, Technology and Innovation Centre, UK

² Department of Materials Science and Metallurgy, University of Cambridge, UK

Misorientation and luminescence of GaN microfins

<u>J. Bruckbauer^{1,2,*},</u> I. Manglano Clavero³, C. Margenfeld³, J. Hartmann³, A. Waag³, A. Winkelmann^{2,4}, C. Trager-Cowan^{1,2}, R. W. Martin¹

¹ Semiconductor Spectroscopy & Devices Group, Department of Physics, SUPA, University of Strathclyde, UK

² Advanced Materials Diffraction Lab, Department of Physics, SUPA, University of Strathclyde, UK
 ³ Institute of Semiconductor Technology & Laboratory for Emerging Nanometrology (LENA),
 Technische Universität Braunschweig, Germany

⁴ Academic Centre for Materials and Nanotechnology, AGH University of Krakow, Poland

Influences of the layer thickness on the morphological and optical properties of cubic GaN thin films grown on 3C-SiC

<u>X. Xu¹</u>, M. Frentrup¹, G. Kusch¹, M. J. Kappers¹, D. J. Wallis^{1,2}, and R. A. Oliver¹

¹ Department of Materials Science and Metallurgy, University of Cambridge, UK

² Centre for High Frequency Engineering, University of Cardiff, UK

Investigations into the Structure-Property Relationship of Porous GaN

<u>Jiawei Zhang</u>, Benjamin Thornley, Galih R. Suwito, Saptarsi Ghosh, Menno Kappers, and Rachel Oliver Cambridge Centre for Gallium Nitride, University of Cambridge, UK

Low-Temperature Conductivity of Porous Gallium Nitride (GaN)

Noppasorn Suphannarat, Saptarsi Ghosh, Francesca Adams, Abhiram Gundimeda, Maruf Sarkar, Menno J. Kappers and Rachel A. Oliver Department of Materials Science and Metallurgy, University of Cambridge, UK

AlGaN as a barrier for vertical transport of electrons in a unipolar heterostructure

<u>Sandeep M. Singh</u>*, Peter Milner, Vitaly Zubialevich, Stefan Schulz, and Peter Parbrook Tyndall National Institute, University College Cork, Ireland

Impact of Channel Layer Thickness in Buffer-Free AlGaN/GaN Hight Electron Mobility Transistor on SiC Substrates

<u>Sahalu Hassan</u>, Kaivan Karami, Afesomeh Ofiare, Abdullah Al-Khalidi, and Edward Wasige School of Science and Engineering, University of Glasgow, UK

CrN/ TiN Multi-Graded Thin Film Sustainable Coatings on Metallic Alloys

<u>A.M. Musanna</u>¹, I. Efeoglu ², G. Gülten², M.A. Maleque², M. Yeşilyurt², B. Yaylalı², B. G. Parvin² ¹ Department of Mechanical Engineering, James Watt School of Engineering, University of Glasgow, UK

² Department of Mechanical Engineering, Engineering Faculty, Atatürk University, Turkey

³ Department of Manufacturing and Materials Engineering, International Islamic University Malaysia, Malaysia

Electrical characterization of defects induced in GaN thin film synthesized using electrodeposition by sputtering deposition

<u>Ali Abdulraoof</u> University of Pretoria, South Africa & Univ. of Elimam Elmahdi, Sudan

Photoluminescence properties of BAIGaN/AIGaN quantum well heterostructures as a function of temperature

<u>Olivia Shortall</u>¹, Vitaly Z. Zubialevich¹, Thomas O'Connor¹, and Peter J. Parbrook ^{1,2}

¹ Tyndall National Institute, University College Cork, Ireland

² Department of Electrical and Electronic Engineering, School of Engineering, University College Cork, Ireland